Notice of Allowability	Application No.	Applicant(s)
	10/625,118	HAERLE
	Examiner	Art Unit
	Beth E. Owens	2824
The MAILING DATE of this communication appe All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this ap or other appropriate communicatio GHTS. This application is subject	oplication. If not included n will be mailed in due course. THIS
1. X This communication is responsive to the amendment filed 24 May 2004.		
2. ☑ The allowed claim(s) is/are <u>19-27; 29-43</u> .		
3. $igspace$ The drawings filed on <u>24 May 2004</u> are accepted by the Ex	caminer.	
4.	been received. been received in Application No. <u>Comments have been received in this communication to file a replying the first application. be submitted. be submitted. con's Patent Drawing Review (PTC) a Amendment / Comment or in the comment of BIOLOGICAL MATERIAL</u>	complying with the requirements CS AMENDMENT or NOTICE OF atton, is deficient. C-948) attached Office action of ings in the front (not the back) of (d). must be submitted. Note the
Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. Interview Summan Paper No./Mail Da 8), 7. Examiner's Amend	ate

Allowance

- 1. Claim 28 has been cancelled.
- 2. Claims 19-27 and 29-43 are allowed.
- 3. The following is a continuing examiner's statement of reasons for allowance:

There is no prior art available nor obvious motivation to combine elements of prior art which teach a method of producing laterally integrated semiconductor components, comprising the steps of: applying at least one first semiconductor component on an epitaxial substrate; layering a mask over said at least one first semiconductor component and said substrate, said mask defining one or more windows to said substrate; and applying at least one other semiconductor component in at least one of said one or more windows; and removing said mask layer by introduction of at least one fluoride based compound into an epitaxy reactor.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Conclusion

4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Beth E. Owens, Ph.D. whose telephone number is 571.272.1882.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Richard Elms, can be reached on 571.272.1869. The fax phone number for the organization where this application or proceeding is assigned is 703.872.9306 for official communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 571.272.2800.

BEO 06.10.04

VAN THU NGUYEN PRIMARY EXAMINER

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